Compendium of Single Event Effect Results from NASA Goddard Space Flight Center

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Abstract — **We present the results of single event effect (SEE) testing and analysis investigating the effects of radiation on electronics. This paper is a summary of test results.**

Index Terms — **Single event effects, spacecraft electronics, digital, linear bipolar, and hybrid devices.**

I. Introduction

NASA spacecraft are subjected to a harsh space environment that includes exposure to various types of ionizing radiation. The performance of electronic devices in a space radiation environment are often limited by their susceptibility to single event effects (SEE). Ground-based testing is used to evaluate candidate spacecraft electronics to determine risk to spaceflight applications. Interpreting the results of radiation testing of complex devices is challenging. Given the rapidly changing nature of technology, radiation test data are most often application-specific and adequate understanding of the test conditions is critical [1].

Studies discussed herein were undertaken to establish the application-specific sensitivities of candidate spacecraft and emerging electronic devices to single-event upset (SEU), single-event latchup (SEL), single-event gate rupture (SEGR), single-event burnout (SEB), and single-event transient (SET).

For total ionizing dose (TID) results, see a companion paper submitted to the 2016 Institute of Electrical and Electronics Engineers (IEEE) Nuclear and Space Radiation Effects Conference (NSREC) Radiation Effects Data Workshop (REDW) entitled "Compendium of Total Ionizing Dose Results from NASA Goddard Space Flight Center" by M. Campola, *et al.* [2].

II. Test Techniques and Setup

A. Test Facilities

All tests were performed between February 2015 and February 2016. Heavy ion experiments were conducted at the Lawrence Berkeley National Laboratory (LBNL) 88-inch cyclotron [3], NASA Space Radiation Laboratory (NSRL) at Brookhaven National Laboratory [4], and at the Texas A&M University Cyclotron (TAMU) [5]. All of these facilities provide a variety of ions over a range of energies for testing. Each device under test (DUT) was irradiated with heavy ions having linear energy transfer (LET) ranging from 0.07 to 80 MeV•cm^2/mg. Fluxes ranged from 1×10^2 to 1×10^5 particles/cm^2/s, depending on device sensitivity. Representative ions used are listed in Tables I, II and III. LETs in addition to the values listed were obtained by changing the angle of incidence of the ion beam with respect to the DUT, thus changing the path length of the ion through the DUT and the "effective LET" of the ion [6]. Energies and LETs available varied slightly from one test date to another.

Proton SEE tests were performed at Northwestern Medicine Chicago Proton Center (CDH) [7], Hampton University Proton Therapy Institute (HUPTI) [8], Mass General Hospital (MGH) Francis H. Burr Proton Therapy [9], Scripps Proton Therapy Center (Scripps) [10], and Tri-University Meson Facility (TRIUMF) [11].

Laser SEE tests were performed at the pulsed laser facility at the Naval Research Laboratory (NRL) [12], [13]. We tested with a pulsed laser at the Naval Research Laboratory using both Single-Photon Absorption (SPA) and Two-Photon Absorption (TPA) techniques previously described in [14].

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TABLE I: LBNL Test Heavy Ions

Ion	Energy (MeV)	Surface LET in Si (MeV•cm^2/mg) (Normal Incidence)	Range in Si (µm)
LBNL 10 MeV per amu tune			
^{18}O	183	2.2	226
^{22}Ne	216	3.5	175
^{40}Ar	400	9.7	130
^{23}V	508	14.6	113
^{65}Cu	660	21.2	108
^{84}Kr	906	30.2	113
^{107}Ag	1039	48.2	90
^{124}Xe	1233	58.8	90

TABLE II: NSRL Test Heavy Ions

Ion	Energy (MeV)	Surface LET in Si (MeV•cm²/mg) (Normal Incidence)	Range in Si (µm)
^{197}Au	32505	24.7	3700

TABLE II: TAMU TEST HEAVY IONS

Ion	Energy (MeV)	Surface LET in Si (MeV•cm²/mg) (Normal Incidence)	Range in Si (µm)
TAMU 15 MeV per amu tune			
^{4}He	98	0.07	3401
^{14}N	210	1.3	428
^{20}Ne	300	2.5	316
^{40}Ar	599	7.7	229
^{63}Cu	944	17.8	172
^{84}Kr	1259	25.4	170
^{109}Ag	1634	38.5	156
^{129}Xe	1934	47.3	156
^{197}Au	2954	80.2	155
TAMU 25 MeV per amu tune			
^{84}Kr	2081	19.8	332
^{139}Xe	3197	38.9	286

amu = atomic mass unit

B. Test Method

Unless otherwise noted, all tests were performed at room temperature and with nominal power supply voltages. Device qualification include SEL high-temperature, V_{CC} plus worst-case and for SEU/SET high-temperature, V_{CC} minus worst-case. Unless otherwise noted, SEE testing was performed in accordance with JESD57 test procedures where applicable [15].

1) SEE Testing - Heavy Ion:

Depending on the DUT and the test objectives, one or more of three SEE test approaches were typically used:

Dynamic – the DUT was continually exercised while being exposed to the beam. The events and/or bit errors were counted, generally by capturing with a high-speed oscilloscope, digital input/output (DIO) device, microprocessor, FPGA, or by comparing the DUT output to an unirradiated reference device or with an expected output (Golden chip or virtual Golden chip methods) [16]. In some cases, the effects of clock speed or device operating modes were investigated. *Results of such tests should be applied with caution due to their application-specific nature.*

Static – the DUT was configured prior to irradiation; data were retrieved and errors were counted after irradiation.

Biased – the DUT was biased and clocked while power consumption was monitored for SEL or other destructive effects. In most SEL tests, functionality was also monitored.

DUTs were monitored for soft errors, such as SEUs, and for hard failures such as SEGR. Detailed descriptions of the types of errors observed are noted in the individual test reports [17], [18].

SET testing was performed using high-speed oscilloscopes controlled via LabVIEW®. Individual criteria for SETs are specific to the device and application being tested. Please see the individual test reports for details [17], [18].

Heavy ion SEE sensitivity experiments include measurement of the linear energy transfer threshold (LET_{th}) and cross section at the maximum measured LET. The LET_{th} is defined as the maximum LET value at which no effect was observed at an effective fluence of 1×10^7 particles/cm². In the case where events are observed at the smallest LET tested, LET_{th} will either be reported as less than the lowest measured LET or determined approximately as the LET_{th} parameter from a Weibull fit. In the case of SEGR and SEB experiments, measurements are made of the SEGR or SEB threshold V_{DS} (drain-to-source voltage) as a function of LET and ion energy at a fixed V_{GS} (gate-to-source voltage).

2) SEE Testing – Proton:

Proton SEE tests were performed in a manner similar to heavy ion exposures. However, because protons usually cause SEE via indirect ionization of recoil particles, results are parameterized in terms of proton energy rather than LET. Because such proton-induced nuclear interactions are rare, proton tests also feature higher cumulative fluences and particle flux rates than heavy ion experiments.

3) SEE Testing - Pulsed Laser

The DUT was mounted on an X-Y-Z stage in front of a 100x lens that produces a spot diameter of approximately 1 µm at full-width half-maximum (FWHM). The X-Y-Z stage can be moved in steps of 0.1 µm for accurate determination of SEE-sensitive regions in front of the focused beam. An illuminator, together with a charge-coupled device (CCD) camera and monitor, were used to image the area of interest thereby facilitating accurate positioning of the device in the beam. The pulse energy was varied in a continuous manner using a polarizer/half-waveplate combination and the energy was monitored by splitting off a portion of the beam and directing it at a calibrated energy meter.

III. TEST RESULTS OVERVIEW

Principal investigators are listed in Table IV. Abbreviations and conventions are listed in Table V. SEE results are summarized in Table VI. Unless otherwise noted all LETs are in MeV•cm²/mg and all cross sections are in cm²/device. All SEL tests are performed to a fluence of 1×10^7 particles/cm² unless otherwise noted.

TABLE IV: LIST OF PRINCIPAL INVESTIGATORS

Principal Investigator (PI)	Abbreviation
Melanie D. Berg	MB
Megan C. Casey	MCC
Michael J. Campola	MJC
Dakai Chen	DC
Raymond L. Ladbury	RL
Jean-Marie Lauenstein	JML
Carl M. Szabo	CS
Jonathan A. Pellish	JP
Edward (Ted) P. Wilcox	TW

TABLE V: ABBREVIATIONS AND CONVENTIONS

LET = linear energy transfer (MeV•cm^2/mg)
LET_{th} = linear energy transfer threshold (the maximum LET value at which no effect was observed at an effective fluence of 1×10^7 particles/cm^2 – in MeV•cm^2/mg)
< = SEE observed at lowest tested LET
> = no SEE observed at highest tested LET
σ = cross section (cm^2/device, unless specified as cm^2/bit)
σ_{maxm} = cross section at maximum measured LET (cm^2/device, unless specified as cm^2/bit)
ADC = analog to digital converter
BiCMOS = bipolar complementary metal oxide semiconductor
BNL=Brookhaven National Laboratory Tandem Van de Graaff
CDH=Northwestern Medicine Chicago Proton Center
CMOS = complementary metal oxide semiconductor
CMRR = common-mode rejection ratio
DAC = Digital to Analog Converter
DUT = device under test
ECC = error correcting code
ES = engineering samples
GSFC = NASA Goddard Space Flight Center
H = heavy ion test
HUPTI = Hampton University Proton Therapy Institute
I_D = drain current
IC = integrated circuit

ID# = identification number
I_{DS} = drain-source current
I_G = gate current
Iout = output current
I_R = reverse leakage current
L = laser test
LaRC = NASA Langley Research Center
LBNL = Lawrence Berkeley National Laboratory
LDC = lot date code
LVDS=Low-Voltage Differential Signaling
min = minimum
MGH = Mass General Hospital Francis H. Burr Proton Therapy
MOSFET = metal-oxide-semiconductor field-effect transistor
NRL = Naval Research Laboratory
NSRL = NASA Space Radiation Laboratory
NSWC = Naval Surface Warfare Center
PI = principal investigator
PIGS = post-irradiation gate stress
PSRR = power supply rejection ratio
REAG = radiation effects and analysis group
SBU = single-bit upset
Scripps = Scripps Proton Therapy Center
SEB = single event burnout
SEDR = single event dielectric rupture
SEE = single event effect
SEFI = single event functional interrupt
SEGR = single event gate rupture
SEL = single event latchup
SET = single event transient
SEU = single event upset
SMU = source-measure unit
SOTA = state of the art
SRIM = the stopping and range of ions in matter
TAMU = Texas A&M University Cyclotron Facility
TDP = thermal design power
TRIUMF=Tri-University Meson Facility
V_{CC} = power supply voltage
V_{DD} = power supply voltage
VDMOS = vertical double diffused MOSFET
V_{DS} = drain-to-source voltage
V_{GS} = gate-to-source voltage
VNAND = vertical-NAND
V_R = reverse bias voltage
V_S = power supply voltage

TABLE VI: SUMMARY OF SEE TEST RESULTS

Part Number	Manufacturer	LDC or Wafer#, REAG ID#	Device Function	Tech-nology	Particle: (Facility/Year/Month) P.I.	Test Results: LET in MeV•cm^2/mg, σ in cm^2/device, unless otherwise specified	Supply Voltage	Sample Size (Number Tested)
Processors:								
Broadwell 5th Gen. Core™ i3-5005U	Intel	15-080	Processor	14nm Gen 5 CMOS and FinFET	P: (MGH; TRIUMF; HUPTI; Scripps) CS H: (TAMU15Aug, TAMU15Dec, TAMU16May) CS	Testing to evaluate Proton facilities and development of test processes. Test results available via Duncan, et al., at this year's Data Workshop. [19]	1.05 V, 3.3 V	10
Skylake 6th Gen. Core™ i5-6600K	Intel	15-081	Processor	14nm Gen 6 CMOS and FinFET	P: (TRIUMF15Nov) CS	Testing to evaluate Proton facilities and development of test processes. Test results available via Duncan, et al., at this year's Data Workshop. [19]	3.3 V, 5V, 12V	1
Skylake 6th Gen. Core™ i3-6100	Intel	15-081	Processor	14nm Gen 6 CMOS and FinFET	H: (TAMU15Dec) CS	Test results available via Duncan, et al., at this year's Data Workshop. [19]	3.3 V, 5V, 12V	1
Skylake 6th Gen. Core™ i3-6100T	Intel	15-081	Processor	14nm Gen 6 CMOS and FinFET	H: (TAMU16May) CS P: (Scripps16May) CS	Testing to evaluate Proton facilities and development of test processes. Test results available via Duncan, et al., at this year's Data Workshop. [19]	3.3 V, 5 V, 12 V	2

Part Number	Manufacturer	LDC or Wafer#, REAG ID#	Device Function	Tech-nology	Particle: (Facility/Year/Month) P.I.	Test Results: LET in MeV•cm²/mg, σ in cm²/device, unless otherwise specified	Supply Voltage	Sample Size (Number Tested)
Memory Devices:								
MT29F128G08CBECBH6	Micron	201448, 14-088	Flash Memory	16 nm CMOS	H: (LBNL2015Aug; 15Dec) DC	SEU LET_{th} < 0.9 MeV•cm²/mg, SEU σ = 1.7×10^{-10} at LET of 58; SEFI: Part is vulnerable to SEFI in static biased and dynamic test modes. SEFI LET_{th} < 0.9; No device functional failure up to LET of 118. Block erase failure $LET_{th} \leq 21.2$ [20]	3.3 V	2
HM628128	Hitachi	9249, 15-082	1Mb SRAM	0.8um CMOS	P: (MGH15Dec; TRIUMF15Oct) TW	Experimental characterization of proton test facilities. Proton SBU σ ~1×10^{-13} cm²/bit. MBU varies with data pattern. [21]	5 V	4
Magnum Test Vehicle	IBM (now Global Foundaries)	No LDC, 15-027	SRAM	45 nm SOI CMOS	P: (CDH15Mar; TRIUMF; Scripps; HUPTI) JP/MCC	Experimental characterization of proton test facilities. Proton SBU σ ~5×10^{-15} cm²/bit. MBU σ ~5×10^{-16} cm²/bit.	0.6 to 1.2 V	1
Si Power Devices:								
BUY15CS23J-01 Eng. Samples	Infineon	1440.60 14-076	MOSFET	Super-junction	H: (TAMU2015Nov21) JML	Primary failure mode: SEGR. 2076-MeV Ta (LET=77): Pass 150 V_{DS} at 0 to -10 V_{GS}; max pass/first fail V_{DS} 140/150V at -15 V_{GS}, 60/70V at -20 V_{GS}. [22]	V_{GS} = 0V to -20V in 5-V steps	5
DG403	Vishay	G1317AB, 15-018	Analog Switch	CMOS	H: (LBNL2015Apr01) MJC	SEL LET_{th} > 84 [23]	+/-15V	6
2N6790	International Rectifier	1427, 15-022	MOSFET	Power	H: (LBNL2015Mar31) MJC; (TAMU2015Apr11) MJC/MCC	Primary failure mode: SEGR. 1634-MeV Ag (LET=44): max pass/first fail -90V/-100V. 2954-MeV Au (LET=87): max pass/first fail VDS -40V/-50V. [24]	0 V_{GS}	2
2N6845	International Rectifier	1427, 15-021	MOSFET	Power	H: (TAMU2015Apr11) MJC/MCC	Primary failure mode: SEGR. 1634-MeV Ag (LET=44): max pass/first fail VDS -70V/-80V 2954-MeV Au (LET=87): max pass/first fail VDS -40V/-50V. [24]	0 V_{GS}	2
LM195	National Semiconductor	No LDC, 15-031	Power Transistor	Bipolar	H: (TAMU2015Apr11) MJC	SEB LET_{th} > 87 (2006-MeV Au) [25]	35 V	4
1N5554	Microsemi	1242, 13-058; and 1318, 14-059	Diode	Si	H: (NSRL 15Mar) MCC	No degradation observed at 500V reverse voltage when irradiated with 31.5 GeV Au.	500 V	62
DSS17-06CR	IXYS	No LDC, 15-084	Diode	Si	H: (LBNL2015Dec19) MCC	No failures observed at 50% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm²/mg). Degradation observed during beam run while biased at 75% of reverse voltage. Post-rad electrical parameter measurements were out of specification. Catastrophic failure was observed at 100% of reverse voltage	600 V	5
FST30100	Microsemi	0715, 14-024	Diode	Si	H: (LBNL2015Aug18) MCC	No failures observed at 100% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm²/mg).	100 V	3
FYPF1545	Fairchild Semiconductor	E13AA, 15-050	Diode	Si	H: (LBNL2015June27) MCC	No failures observed at 100% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm²/mg).	45 V	3
FYPF2045	Fairchild Semiconductor	E23AD, 15-051	Diode	Si	H: (LBNL2015June27) MCC	No failures observed at 100% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm²/mg).	45 V	3
FYPF2006	Fairchild Semiconductor	D50AB, 15-052	Diode	Si	H: (LBNL2015June27) MCC	No failures observed at 100% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm²/mg).	60 V	3
FYPF1010	Fairchild Semiconductor	D34AA, 15-053	Diode	Si	H: (LBNL2015June27) MCC	No failures observed at 100% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm²/mg).	100 V	3
MBR2045	Diodes, Inc.	1339, 15-054	Diode	Si	H: (LBNL2015June27) MCC	Degradation observed during beam run while biased at 100% of reverse voltage, but all parameters remained within specification when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm²/mg).	45 V	3
MBR2060	Diodes, Inc.	1339, 15-057	Diode	Si	H: (LBNL2015June27) MCC	Degradation observed during beam run while biased at 100% of reverse voltage, but all parameters remained within specification when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm²/mg).	60 V	3

Part Number	Manufacturer	LDC or Wafer#, REAG ID#	Device Function	Tech-nology	Particle: (Facility/Year/Month) P.I.	Test Results: LET in MeV•cm^2/mg, σ in cm^2/device, unless otherwise specified	Supply Voltage	Sample Size (Number Tested)
MBR20200	Diodes, Inc.	1348, 15-060	Diode	Si	H: (LBNL2015June27) MCC	No failures observed at 50% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm^2/mg). Catastrophic failure was observed at 75% and 100% of reverse voltage.	200 V	4
MBR40250	On Semiconductor	No LDC, 15-085	Diode	Si	H: (LBNL2015Dec19) MCC	No failures observed at 50% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm^2/mg). Catastrophic failure was observed at 75% and 100% of reverse voltage.	250 V	5
MBRF20100	Diodes, Inc.	1346, 15-058	Diode	Si	H: (LBNL2015Aug18) MCC	Degradation observed during beam run while biased at 75% of reverse voltage, but all parameters remained within specification when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm^2/mg). Catastrophic failures observed when biased at 100% of reverse voltage.	100 V	4
MBRF30100	Diodes, Inc.	1336, 15-059	Diode	Si	H: (LBNL2015June27) MCC	No failures observed at 50% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm^2/mg). Catastrophic failure was observed at 75% and 100% of reverse voltage.	100 V	4
LXA03T600	Power Integrations	No LDC, 15-073	Diode	Si	H: (LBNL2015Aug18) MCC	No failures observed at 50% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm^2/mg). Catastrophic failure was observed at 75% and 100% of reverse voltage.	600 V	11
LXA20T600	Power Integrations	No LDC, 15-075	Diode	Si	H: (LBNL2015Aug18) MCC	No failures observed at 50% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm^2/mg). Catastrophic failure was observed at 75% and 100% of reverse voltage.	600 V	11
VS-APH3006-N3	Vishay	No LDC, 15-076	Diode	Si	H: (LBNL2015Aug18) MCC	No failures observed at 100% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm^2/mg).	600 V	5
SBL8L40	Vishay	1515, 15-044	Diode	Si	H: (LBNL2015Aug18) MCC	No failures observed at 100% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm^2/mg).	40 V	3
SBL1040	Vishay	1412, 15-045	Diode	Si	H: (LBNL2015Aug18) MCC	No failures observed at 100% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm^2/mg).	40 V	3
SBL1045	Diodes, Inc.	0924, 15-049	Diode	Si	H: (LBNL2015Aug18) MCC	No failures observed at 100% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm^2/mg).	45 V	3
SBL3040	Vishay	1410, 15-046	Diode	Si	H: (LBNL2015Aug18) MCC	No failures observed at 100% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm^2/mg).	40 V	3
SBR20A300	Diodes, Inc.	No LDC, 15-086	Diode	Si	H: (LBNL2015Dec18) MCC	No failures observed at 50% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm^2/mg). Catastrophic failure was observed at 75% and 100% of reverse voltage.	300 V	5
SBR30300	Diodes, Inc.	No LDC, 15-087	Diode	Si	H: (LBNL2015Dec18) MCC	No failures observed at 50% of reverse voltage when irradiated with 1233 MeV Xe (LET = 58.8 MeV•cm^2/mg). Catastrophic failure was observed at 75% and 100% of reverse voltage.	300 V	5
SiC Devices:								
CPM2-1200-0025B	CREE	1327, 13-069; FM113-16, 15-067	MOSFET	SiC Gen 2 VDMOS	H: (LBNL2015Dec18) JML	996-MeV Xe (LET=65 in SiC): Immediate catastrophic SEB at V_{DS} ≤ 600 V, threshold not identifiable. At lower V_{DS}, degradation of I_G and I_D with fluence increased with temperature. 361-MeV Ar (LET=11 in SiC): Latent gate damage 200V < V_{DS} ≤ 300V; I_{DS} degradation with fluence 300V < V_{DS} ≤400V (note: max V_{DS} tested=500V).[26]	0 V_{GS}	11
CPM3-3300 Eng. Samples	CREE	94311CJ12, 15-040	MOSFET	SiC Gen 3 VDMOS	H: (TAMU2015Jun5, LBNL2015Aug23) JML	Contact PI for test results (data proprietary)	0 V_{GS}	6
Test chip	GE	WD04/ DH10 14-081	Diode	SiC IC	H: (TAMU2015Apr12; LBNL2015Dec18) JML	Contact PI for test results (data proprietary)	-100 V	2
Eng. Samples, various	GE	14-078, 14-080	Diodes	SiC discrete	H: (TAMU2015Apr12) JML	Contact PI for test results (data proprietary)	Various	11
Eng. Samples	GE	15-041	MOSFET	SiC VDMOS	H:(TAMU2015Jun3, TAMU2015Nov21) JML	Contact PI for test results (data proprietary)	0 V_{GS}	12

Part Number	Manufacturer	LDC or Wafer#, REAG ID#	Device Function	Tech-nology	Particle: (Facility/Year/Month) P.I.	Test Results: LET in MeV•cm²/mg, σ in cm²/device, unless otherwise specified	Supply Voltage	Sample Size (Number Tested)
STPSC1006D	STMicroelectronics	LDC unknown, 15-038	Diode	SiC	H: (LBNL2015Aug23) JML	765-MeV Kr (LET=34 in SiC): Onset V_R for I_R degradation with fluence falls off faster with angle than simple cosine law. Onset at normal incidence = 200V < V_R ≤ 225V.[27]	Various V_R and angles	4
Test chip	GE	WD04/ DH10, 14-079	Frequency Divider	SiC IC	H: (TAMU2015Apr12) MCC/JML	Contact PI for test results (data proprietary)	12 V- 20 V	5
Test chip	GE	WD04/ DH10, 14-081	Ring Oscillator	SiC IC	H: (TAMU2015Apr12; LBNL2015Dec18) MCC/JML	Contact PI for test results (data proprietary)	5 V- 20 V	1
Test chip	GE	WD04/ DH10 14-081	Op Amp	SiC IC	H: (TAMU2015Apr12; LBNL2015Dec18) MCC/JML	Contact PI for test results (data proprietary)	20 V	2
IC test chip	Ozark IC	14-046	Logic Device	SiC IC	H (LBNL2015Jun02) MCC	Contact PI for test results (data proprietary)	15 V	3
Op Amps:								
OPA2107	Texas Instruments	1144, 15-005	Difet Op Amp	Bipolar	H: (TAMU2015Apr11) MJC	The parts passed with supply voltages starting at +/-5V up to +/-15V at an LET of 53 MeV•cm²/mg. At an LET of 87.1 MeV•cm²/mg they passed from +/-5V to +/-13V.	Various	3
AD8038	Analog Devices	JX676, 15-025	XFCB Op Amp	Bipolar	H: (TAMU2015Apr11) MJC	SEB/SEDR LET_{th} > 87 [28]	+/-15V	3
LT2078	Linear Technology	1180, 15-024	Op Amp	Bipolar	H: (TAMU2015Apr11) MJC	SEB/SEDR LET_{th} > 61.3 [29]	+/-15V	3
OP470	Analog Devices	1419A, 15-032	Op Amp	Bipolar	H:(LBNL2015Jun02) MJC/MCC	SEDR LET_{th} < 49.3 MeV•cm²/mg. Normal incidence is worst case and SEDR observed at V_{DD} = ±12 V under these conditions.[30]	±6V to ±15V	5
OP200	Analog Devices	9584 0206AA 0736A	Op Amp	Bipolar	P: (HUPTI2015Jul, CDH2015Sep) RL	No SEDR seen for V_S=14.3; >3x10¹¹ 200-MeV p/cm² @ HUPTI; >2x10¹² 200-MeV p/cm² @ CDH	14.3 V	9
OP400	Analog Devices	0502B 0215B	Op Amp	Bipolar	P: (HUPTI2015Jul, CDH2015Sep) RL	No SEDR seen for V_S=14.3; >3x10¹¹ 200-MeV p/cm² @ HUPTI; >2x10¹² 200-MeV p/cm² @ CDH	14.3 V	10
FPGA:								
RT4G150-CB1657MSX449	Microsemi	1534, 15-083	FPGA	65nm CMOS	H: (TAMU2015Dec; LBNL2016Mar) MB	SEE LET_{th} > 5 [31] [32] [33]	1.5; 2.5; and 3.3 V	1 Rev B; 1 Rev C
XC7K325T Kintex7	Xilinx	1349, 14-001	FPGA	25nm CMOS	H: (TAMU2015Apr10; TAMU2015Aug12) MB L: (NRL2016) MB	H: SEU LET_{th} < 0.07 (configurable memory); 100ma current jumps were observed. L: Tested to evaluate different mitigation strategies. [33] [34] [35]	Varies w/data sheet	3
Other Devices:								
SPC5606B	NXP (Freescale)	1M03Y, 15-066	Automotive Microcontroller	90nm CMOS	H: (LBNL2015Aug22; LBNL2015Dec18) TW	SEFI: LET_{th} < 0.89, σ_{maxm} = 3.93 x10⁻³ cm² at LET = 68.1 SEL: LET_{th} = 6.09 Single-bit SRAM Error: LET_{th} < 0.89 Double-bit SRAM Error: LET_{th} = 1.78 Double-bit Flash Error: LET_{th} > 68.1 No catastrophic/unrecoverable device failures observed up to maximum LET tested of 68.1	5 V	4
AD5328	Analog Devices	4456, 15-026	DAC	CMOS	H:(LBNL2015Apr) MJC/TW	SEL 4 < LET_{th} < 6 at elevated temperature	5 V	4
MAX9180	Maxim	1421, 15-030	LVDS	CMOS	H: (TAMU2015Apr11) MJC	SEL 40.7<LET_{th}<43.6 [36]	3.3-3.6 V	4
ADV212	Analog Devices	1216, 1220, 13-053	Video Codec	CMOS	L: (NRL2016Oct14) TW	Latch-ups observed. Tested to evaluate off-chip recovery system.	Various	1

IV. TEST RESULTS AND DISCUSSION

As in our past workshop compendia of NASA Goddard Space Flight Center (GSFC) test results, each DUT has a detailed test report available online at http://radhome.gsfc.nasa.gov [17].

This section contains summaries of testing performed on a selection of featured parts.

A. Cree CPM2-1200-0025B SiC VDMOS

Heavy-ion SEE tests were conducted at the Lawrence Berkeley National Laboratory (LBNL) in vacuum with 10 MeV/u xenon or argon. The bare die were assembled in TO-3 headers without lids, and a controlled 1-mil parylene-C coating was then deposited to prevent the bond wires from arcing under high voltage. Beam energy at the surface of the die after passing through the coating was determined using the stopping and range of ions in matter (SRIM) code [37] to be

966 MeV for xenon, with an LET in SiC of 65 MeV•cm^2/mg and a penetration range of 45 µm; for argon, energy = 361 MeV, LET = 11 MeV•cm^2/mg, and range = 77 µm. Prior to and after each irradiation, the gate-source leakage current (I_{GSS}) and drain-source leakage current (I_{DSS}) and/or the breakdown voltage were measured. During irradiation, V_{GS} was held at 0 V, a positive V_{DS} was applied, and the gate and drain currents were continuously measured and recorded via Keithley 2635A or 2400, and 2657A source-measure units (SMUs).

Immediate catastrophic failure of the device occurred upon xenon beam exposure at 600 V_{DS}. At lower voltage, permanent degradation of the drain and/or gate leakage current occurred linearly as a function of fluence. The slope of this degradation increased with increasing temperature, as can be seen in Fig. 1 where the change in leakage current during the beam run as a function of fluence is shown for a single part irradiated at 300 V with xenon at 28 °C, 75 °C, and 97 °C case temperature. In silicon power MOSFETs, SEB susceptibility during radiation testing is often reduced by elevated temperature due to the decreased charge mobility. SEB in silicon power MOSFETs typically involves the turn-on of the parasitic bipolar junction transistor. The behavior of silicon carbide power MOSFETs differs: in addition to immediate catastrophic failure, there is a voltage range at which permanent substantial degradation of leakage current occurs that worsens with increasing temperature. It is most likely that the mechanisms in SiC MOSFETs are direct and do not involve the parasitic bipolar transistor.
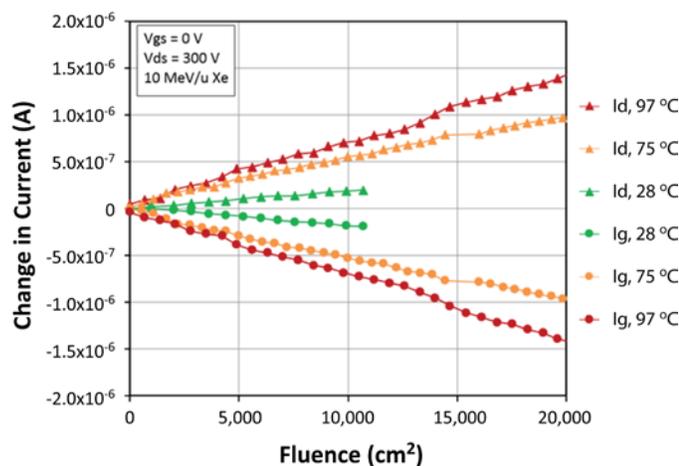
Fig. 1. Degradation of both drain and gate currents during irradiation with xenon while biased at 0 V_{GS} and 300 V_{DS} is very linear with ion fluence. The degradation rate during irradiation increases with increasing case temperature.

In addition to burnout in the SiC material, the MOSFETs are susceptible to latent damage in the gate oxide. As shown in Fig. 2 for the CPM2-1200-0025B irradiated under 100-V drain-source bias with xenon, this degradation is fluence-dependent, such that no single ion causes the part to go out of specification under these conditions. Irradiation with the much lighter ion, argon, at 100 V_{DS} up to a fluence of 5×10^5 cm^{-2} resulted in no measurable change in I_{GSS}. [38]
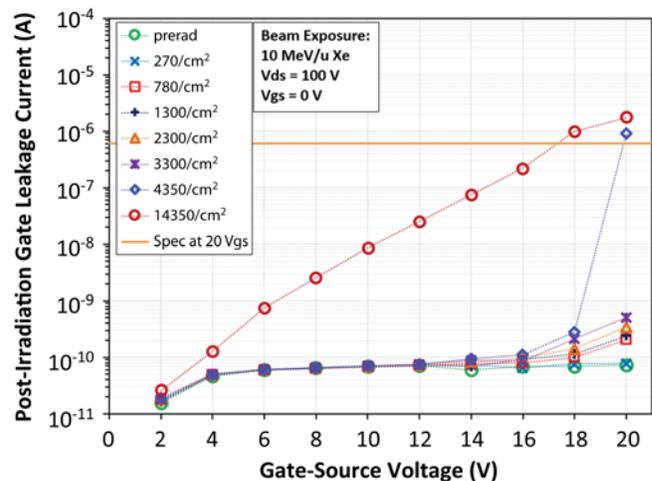
Fig 2. Upon irradiation with xenon at 100 V_{DS}, only latent damage to the gate leakage current was found. The post-irradiation gate stress test reveals increasing gate leakage current with increasing fluence.

B. Intel Core™ i3-5005u "Broadwell" Mobile Processor; Core™ i5-6600K, i3-6100, i3-6100T "Skylake" Desktop Processor

Commercially available state-of-the-art (SOTA) processor technologies remain an active topic of our interest. Our efforts remain focused on products offered by Intel that are based on their 14nm "Tri-Gate" design process: The Core™ i3-5005u "Broadwell" family mobile processor and a trio of "Skylake" family desktop parts: the Core™ i5-6600K, i3-6100, and i3-6100T. While testing these devices remains, in and of itself, a fascinating challenge, the real highlight of our activity was the opportunity to leverage inter- and intra-agency cooperative efforts to achieve mutual end goals.

At last year's NSREC Data Workshop, we presented TID test results on the i3-5005u part, continuing a long-standing working relationship with Naval Surface Warfare Center (NSWC) Crane [35]. Within this study, we detailed an in-situ test designed to "stress" the part with an intensive workload after periodic amounts of TID exposure. Due to time constraints, the DUT could only be tested up to 4 Mrad (Si), but no hard failures occurred.

Prior to our TID testing at NSWC Crane, an invitation was extended by the NEPP Program to participate in their evaluation of North American proton facilities [36]. In exchange for the opportunity to collect interesting data at various sites, our challenge was to familiarize ourselves with the process of operating unfamiliar beam lines and recording observations detailing our perceived level of difficulty with respect to experiment setup.

From May of 2015 to May of 2016, our "Broadwell" test setup would travel to Scripps, HUPTI, TRIUMF, and MGH for proton testing. Fig. 3 shows the Broadwell test set-up at Scripps and Fig. 4 shows the gantry room at HUPTI. In-between proton facility visits, we also conducted heavy ion tests with Ne and Ar at TAMU.
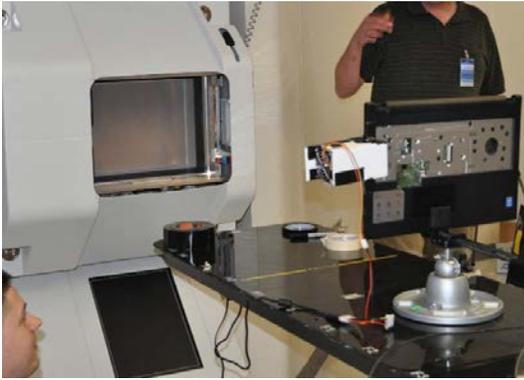
Fig. 3. Broadwell i3-5005u test setup at Scripps.

Fig. 4. Broadwell i3-5005u in gantry room at HUPTI.

Fig. 5. Test operator finalizing Skylake i5-6600K test setup at TRIUMF facility.

With regard to our "Skylake" family processors, our selection of DUTs reflected market availability at the time of the facility visit: the 91W thermal design power (TDP) Core™ i5-6600K (11/2015 TRIUMF), Fig. 5 shows the operator finalizing the test setup at TRIUMF, the 51W TDP Core™ i3-6100 (12/2015 TAMU), and the 35W TDP Core™ i3-6100T (5/2016 TAMU & SCRIPPS). The goal was to be ready to acquire data points as circumstances and test trips warranted. Fig. 6 shows the Skylake set-up for TAMU and Fig. 7 shows a close up of the exposed die.

Data collected has been combined with NSWC independently collected test results. See A. R. Duncan, et al., for complete details of this work and test setup. [19]

As we continue the proton facility study combined with our processors / SOTA technology evaluation, we hope to yield more information on how these parts behave under irradiation, and further refine how best to conduct tests on these complex devices. At the same time, with these parts being relatively inexpensive, they can continue to serve as a simple means to understand the inner workings of various test facilities and provide an infinite source of entertainment to the investigators.

Fig. 6. Skylake i3-6100 test setup at TAMU.
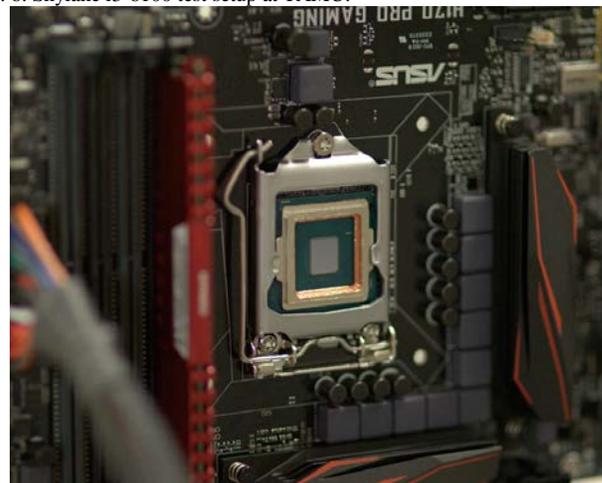
Fig. 7. Close up showing bored out heat spreader and exposed, thinned die.

C. Hitachi HM628128 1Mb SRAM

The Hitachi HM628128LP-10 is a 1 Mbit (128k x 8) SRAM built on a 0.8μm CMOS process. The devices tested have a date code of 9249. Both ground-test and in-flight data have previously been published on this part in [41, 42, 43, 44]. It was selected to be the test vehicle for a series of proton experiments intended to directly compare different proton facilities, both scientific and medical.

The HM628128LP-10 was tested at TRIUMF in Vancouver, BC, Canada, and exposed to 480 MeV and 105 MeV proton beams. Each run was to a total fluence of 1×10^{10} protons over approximately 100 seconds. That fluence produces approximately 1000 byte-errors in this device, representing about 1% of the memory array. Prior to each run, the part was power-cycled and programmed with a repeating data pattern. The part was irradiated under nominal bias, and then read to determine the number of addresses in error. This process was repeated several times for each data pattern at each proton energy. A second test was performed at Massachusetts General Hospital's Proton Therapy Center (MGH). The devices were configured and tested in the same manner as before, but exposed to a 200 MeV proton beam.

SEU cross-sectional data were obtained from both tests and plotted [Fig. 8]. Additionally, total ionizing dose was logged for each run, and cross-sectional data re-plotted as a function of cumulative dose [Fig. 9] to verify the total dose limitations of this device. SEU rates began to increase rapidly after approximately 14 krad (Si) of proton irradiation regardless of energy tested. [21]

The data from TRIUMF, MGH, and previously published data on this part will be utilized as a baseline for comparing additional proton test facilities across a variety of proton energies. It is expected that further data will be needed to shed light on the apparent inconsistencies in proton energy vs upset rate suggested by the initial results of Fig. 9.
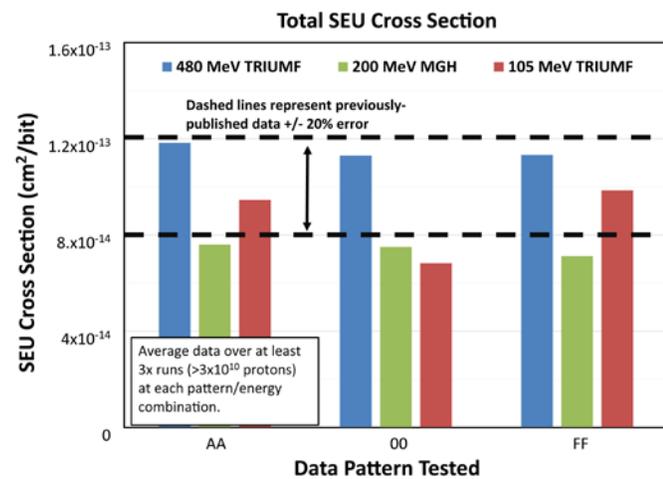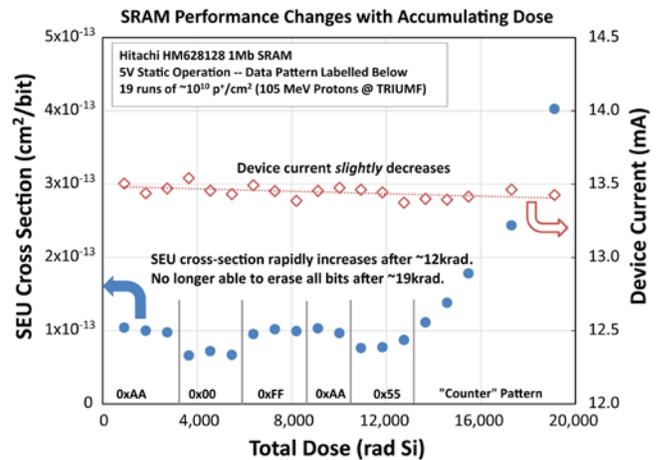
Fig. 9. Changes in SEU cross section (left axis) and device operating current (right axis) as a function of accumulated dose measured at TRIUMF.

D. Analog Devices OP470 Operational Amplifier

The OP470 is a high-performance monolithic quad operational amplifier with exceptionally low voltage noise. The OP470 features an input offset voltage below 0.4 mV and an offset drift under 2 μV/°C, guaranteed over the full military temperature range. Input bias is under 25 nA which reduces errors due to signal source resistance. The OP470's CMRR of over 110 dB and PSRR of less than 1.8 μV/V significantly reduce errors due to ground noise and power supply fluctuations. The OP470 is unity-gain stable with a gain-bandwidth product of 6 MHz and a slew rate of 2 V/μs.

The parts were prepared for testing at LBNL by mechanically delidding each device. The parts were then soldered to small printed circuit boards (PCBs) that were designed specifically for this testing. Because this is a quad part, each op amp in the package was tested in a different configuration for analyzing transients and the destructive effects. In Fig. 10, the test circuits for one device (labeled A) were built to model/approximate the intended application. The configuration of device A was an application specific feedback design. This application-specific configuration also included an application-specific filter on the output. The second op amp (B) implemented the same application-specific feedback configuration, but did not include the output filter. This was used to determine the actual size of the transients generated by the op amp in the application-specific configuration. The third op amp (C), was a simple voltage follower with a gain of 1, but it also had the filter on the output. Finally, device D was also a unity gain voltage follower with no filter on the output.

Because other work had indicated SEDR has been observed in other Analog Device's parts from the same product lines [45], it was necessary to determine the conditions under which SEDR occurred in this part. Destructive SEEs were observed during this testing; however, none were observed at the application supply voltage of ±6 V for any ion tested. After determining the part was not susceptible to destructive SEEs at the application voltage with any ion tested, the supply voltage was incrementally increased by ±1 V and irradiated until SEDR was observed, or the particle fluence reached 1×10^7

Fig. 8. Total SEU cross section measured at TRIUMF, with data broken down by memory pattern and beam energy.

particles/cm^2. No destructive events were observed while irradiated at a 60° angle of incidence.

In addition to identifying the conditions under which the OP470 is susceptible to SEDR, we also captured transients for the four different circuit configurations. Figs. 10 a-d show the worst-case transients generated by the ions tested for each circuit configuration. Fig. 11 shows the SET cross section for each circuit configuration. The worst-case transients are approximately 1.5 µs wide and just under 1 V in amplitude. [30]

(a)

(b)

(c)

(d)
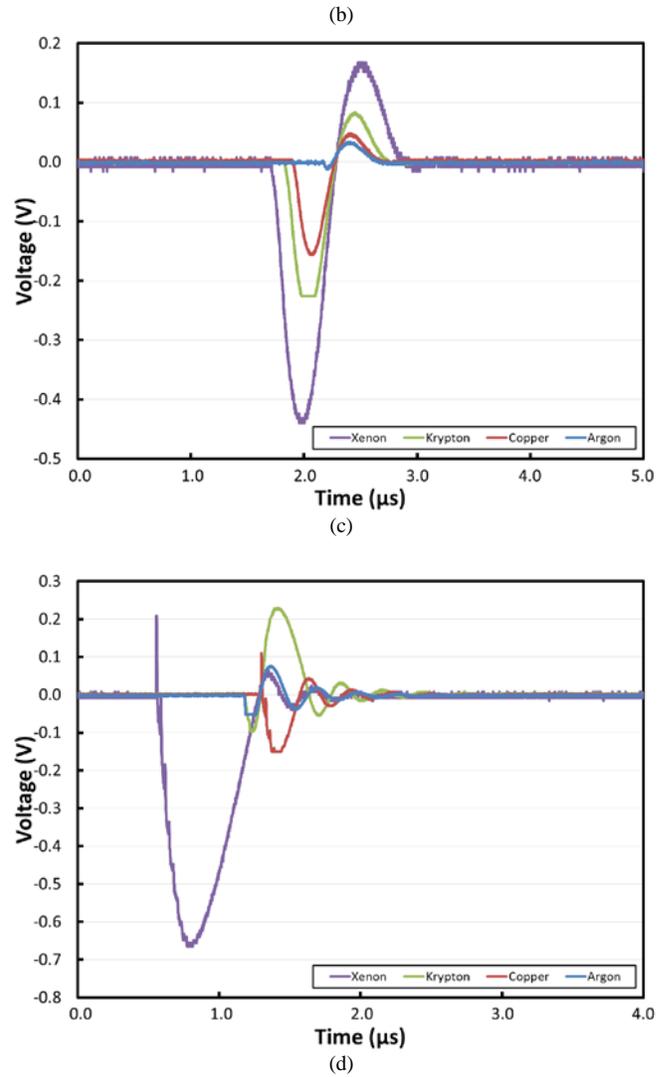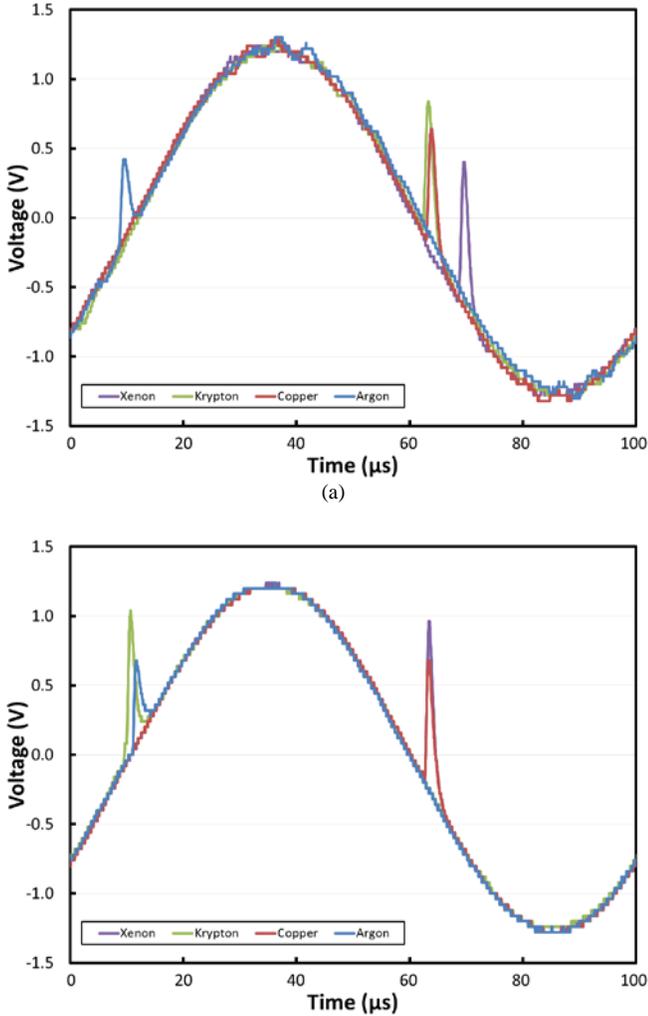
Fig. 10. Representative worst-case transients are shown for (a) the application-specific circuit configuration with the application-specific output filter, (b) the application-specific circuit configuration with no output filter, (c) a unity gain voltage follower with the application-specific output filter, and (d) a unity gain voltage follower with no output filter. Transients generated from argon (LET = 7.27 MeV•cm^2/mg) are shown in blue, copper (LET = 16.5 MeV•cm^2/mg) is shown in red, krypton (LET = 25.0 MeV-cm2/mg) in green, and xenon (LET = 49.3 MeV•cm^2/mg) in purple.
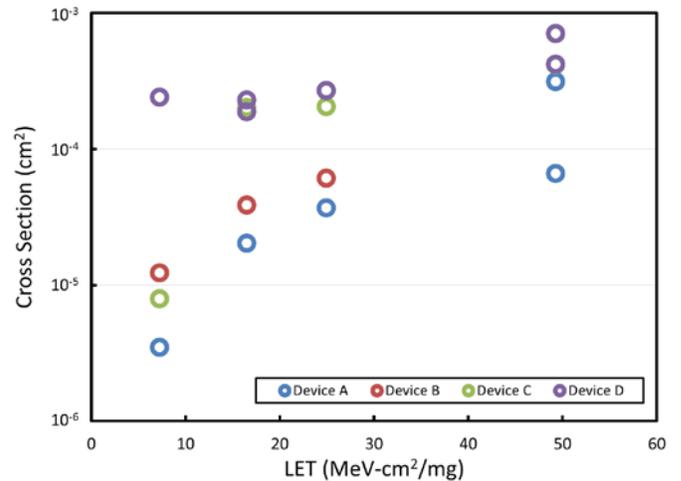
Fig. 11. The cross-section versus LET plot for the four different OP470 circuit configurations tested.

V. SUMMARY

We have presented current data from SEE testing on a variety of mainly commercial devices. It is the authors' recommendation that these data be used with caution. We also highly recommend that lot testing be performed on any suspect or commercial device.

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